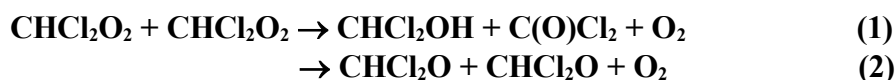


# IUPAC Task Group on Atmospheric Chemical Kinetic Data Evaluation – Data Sheet oRCIOx54

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This data sheet updated: 27<sup>th</sup> January 2006.



## Rate coefficient data ( $k = k_1 + k_2$ )

$k/\text{cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$	Temp./K	Reference	Technique/ Comments
<i>Absolute Rate Coefficients</i>			
1-10 x 10 <sup>-12</sup>	300	Catoire et al., 1996	FP-UVA (a)
(7.0 ± 1.8) x 10 <sup>-12</sup>	298	Biggs et al., 1999	DF-LIF (b)
<i>Branching Ratios</i>			
$k_2/k \geq 0.85$	305	Sanhueza and Heicklen, 1975	UVP-IR (c)
$k_2/k \geq 0.88$	298	Niki et al., 1980	UVP-FTIR (d)
$k_2/k \geq 0.85$	298	Catoire et al., 1996	UVP-FTIR (e)
$k_2/k \geq 0.9$	250-325		FP-UVA (f)

## Comments

- Flash photolysis of CHCl<sub>3</sub> in the presence of CH<sub>3</sub>OH-O<sub>2</sub>-N<sub>2</sub> mixtures at a total pressure of 1000 mbar. Decays in transient absorption signals (with contributions from CHCl<sub>2</sub>O<sub>2</sub> and HO<sub>2</sub>) were recorded in the wavelength range 220 nm to 250 nm. Approximate value of  $k$  derived in conjunction with determination of the rate coefficient for the reaction of CHCl<sub>2</sub>O<sub>2</sub> with HO<sub>2</sub>, using a five reaction mechanism. Authors indicate that best fits were obtained using values of  $k$  close to those measured for the self reactions of CH<sub>2</sub>ClO<sub>2</sub> and CCl<sub>3</sub>O<sub>2</sub> (which are almost identical) in the same laboratory (Catoire et al., 1994, 1996), and recommend that  $k$  is the average these determinations:  $2.6 \times 10^{-13} \exp[(800 \pm 60)/T] \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$  over the temperature range 273 K to 460 K, with  $k = (3.8 \pm 1.4) \times 10^{-12} \text{ cm}^3 \text{ molecule}^{-1} \text{ s}^{-1}$  at 298 K.
- Experiments performed at pressures in the range 1.3 to 4 mbar. CHCl<sub>2</sub>O<sub>2</sub> radicals were produced by the F + CH<sub>2</sub>Cl<sub>2</sub> reaction, with subsequent addition of O<sub>2</sub>. CHCl<sub>2</sub>O<sub>2</sub> radicals were monitored indirectly by titration to NO<sub>2</sub> following reaction with excess NO, with LIF detection of NO<sub>2</sub>. ClO radicals generated by the secondary chemistry were also titrated to NO<sub>2</sub> under the experimental conditions.  $k$  values were extracted by numerical simulation of the results, using an 11 reaction scheme to take account possible of secondary reactions.
- Photolysis of Cl<sub>2</sub> in the presence of CH<sub>2</sub>Cl<sub>2</sub>-O<sub>2</sub>-N<sub>2</sub> mixtures. In situ monitoring of products by IR showed formation of CHClO as the dominant product as part of an efficient chain mechanism. C(O)Cl<sub>2</sub> was observed as a minor product. Listed quantum yield based on the reported quantum yield of 5.9 for CHClO formation.
- Photolysis of Cl<sub>2</sub> in the presence of CH<sub>2</sub>Cl<sub>2</sub>-O<sub>2</sub>-N<sub>2</sub> mixtures. In situ monitoring of products by FTIR spectroscopy showed formation of CHClO as the dominant product as part of an efficient chain mechanism. C(O)Cl<sub>2</sub> was observed as a minor product. Listed quantum yield based on the reported quantum yield of 7.5 for CHClO formation.
- Photolysis of Cl<sub>2</sub> or F<sub>2</sub> in the presence of CH<sub>2</sub>Cl<sub>2</sub>-O<sub>2</sub>-N<sub>2</sub> mixtures. In situ monitoring of products by FTIR spectroscopy showed formation of CHClO and C(O)Cl<sub>2</sub> with yields of ca. 85% and 5% respectively. No other primary products were detected.

- (f) Flash photolysis of  $\text{Cl}_2$  in the presence of  $\text{CH}_2\text{Cl}_2\text{-O}_2\text{-N}_2$  mixtures over the temperature range 250 K to 325 K demonstrated efficient chain regeneration of  $\text{CHCl}_2\text{O}_2$  in the system.

### Preferred Values

$k_2/k = 1.0$  at 298 K.

#### Reliability

$\Delta(k_2/k) = {}^{+0.0}_{-0.15}$  at 298 K.

#### Comments on Preferred Values

The reported dominant chain formation of  $\text{HC(O)Cl}$  from  $\text{CH}_2\text{Cl}_2$  oxidation in a number of product studies (Sanhueza and Heicklen, 1975; Niki et al., 1980; Catoire et al., 1996) has established that the self-reaction of  $\text{CHCl}_2\text{O}_2$  proceeds almost exclusively via formation of  $\text{CHCl}_2\text{O}$  radicals (channel (2)), which decompose by elimination of  $\text{Cl}$ . This is also supported by the failure to detect  $\text{CHCl}_2\text{OH}$  in all the product studies, which would otherwise provide evidence for channel (1). The efficient chain regeneration of  $\text{CHCl}_2\text{O}_2$  radicals observed in the  $\text{Cl}_2\text{-CH}_2\text{Cl}_2\text{-O}_2\text{-N}_2$  flash photolysis experiments of Catoire et al. (1996), is also consistent with the dominance of channel (2) over a wide temperature range.

The reported determinations of  $k$  (Catoire et al., 1996; Biggs et al., 1999) are subject to substantial uncertainties, owing to the complexity of the secondary chemistry. Catoire et al. (1996) report only a broad range for  $k$  at 300K, based on simulations of a complex system in which competitive removal of  $\text{CHCl}_2\text{O}_2$  by reaction with  $\text{HO}_2$  was occurring (see note (a) above). The discharge flow determination of Biggs et al. (1999) was complicated by indirect detection of  $\text{CHCl}_2\text{O}_2$  (which also had contributions from  $\text{ClO}$ ), and possible secondary chain removal of  $\text{CHCl}_2\text{O}_2$  via reactions with  $\text{Cl}$  and  $\text{ClO}$ . Consequently, no firm recommendation for  $k$  is currently possible, and further kinetics studies are required.

### References

- Biggs, P., Canosa-Mas, C. E., Percival, C. J., Shallcross, D. E. and Wayne, R. P.: *Int. J. Chem. Kinet.* 31, 433, 1999.
- Catoire, V., Lesclaux, R., Lightfoot, P. D. and Rayez, M.-T.: *J. Phys. Chem.* 98, 2889, 1994.
- Catoire, V., Lesclaux, R., Schneider, W. F. and Wallington, T. J.: *J. Phys. Chem.* 100, 14356, 1996.
- Niki, H., Maker, P. D., Savage, C. M. and Breitenbach, L. P.: *Int. J. Chem. Kinet.* 12, 1001, 1980.
- Sanhueza, E. and Heicklen, J.: *J. Phys. Chem.* 79, 7, 1975.